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TC 3700 Inventor Search Program

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Serial Number: 10621752

- 1.) See attached printout of inventors listed in
PALM**

- 2.) See attached EAST Inventor Search
Printout shows Inventor search terms**

US 20060038212 A1	20060223	Structure for amorphous carbon based non-volatile memory	257/295		Moore; John et al.
US 20060036649 A1	20060216	Index extraction from documents	707/200		Simske; Steven J. et al.
US 20060036614 A1	20060216	Index extraction from documents	707/100		Simske; Steven J. et al.
US 20060036566 A1	20060216	Index extraction from documents	707/1		Simske; Steven J. et al.
US 20060033125 A1	20060216	Transistor with nitrogen-hardened gate oxide	257/213		Moore; John T.
US 20060031992 A1	20060216	Support device for positioning a patient in a prone position	5/630		Moore; John
US 20060031093 A1	20060209	Computerized method and system for communicating agreements and/or discrepancies in image interpretation	705/2	382/128	Serrano; Laura Kathleen et al.
US 20060024617 A1	20060202	Products with data-encoding pattern	430/311		Gonzalez; Manuel et al.
US 20060022352 A1	20060202	Front-end processing of nickel plated bond pads	257/786		Moore; John et al.
US 20060015033 A1	20060119	ECG electrode characterization and compensation	600/509		Blakley; Daniel R. et al.
US 20060011969 A1	20060119	Use of dilute steam ambient for improvement of flash devices	257/315	365/185.01	Weimer; Ronald A. et al.
US 20060009028 A1	20060112	Anti-reflective coating doped with carbon for use in integrated circuit technology and method of formation	438/636		Weimer; Ronald A. et al.
US 20060008998	20060112	Semiconductor assemblies, methods	438/287	438/775; 438/786	Beaman; Kevin L. et

A1		of forming structures over semiconductor substrates, and methods of forming transistors associated with semiconductor substrates			al.
US 20060006421 A1	20060112	Memory device, programmable resistance memory cell and memory array	257/204	257/536	Moore; John T. et al.
US 20060005296 A1	20060112	Human motor control device and methods	2/159		Moore; John
US 20060001690 A1	20060105	Image reproduction	347/19		Martinez; Oscar et al.
US 20060001668 A1	20060105	Forecast weather video presentation system and method	345/473	345/629	Johnson; Chad W. et al.
US 20050268662 A1	20051208	Coatings for glass molding dies and forming tools	65/374.11	65/374.12; 65/374.13	Moore, John J. et al.
US 20050267914 A1	20051201	Method and apparatus for updating a database using table staging and queued relocation and deletion	707/200		Moore, John Walter et al.
US 20050266635 A1	20051201	Graded GexSe100-x concentration in PCRAM	438/238		Moore, John T. et al.
US 20050263261 A1	20051201	Functionally graded alumina-based thin film systems	164/312	164/138	Moore, John J. et al.
US 20050261400 A1	20051124	Color-converting photoluminescent film	524/99	106/499; 252/301.16; 252/301.35	Yang, Maizhi et al.
US 20050240424 A1	20051027	System and method for hierarchical attribute extraction within a call handling system	705/1		Lin, Xiaofan et al.
US	20051027	Method and system	704/246		Simske,

20050240407 A1		for presenting content to an audience			Steven John et al.
US 20050228668 A1	20051013	System and method for automatic generation of dialog run time systems	704/256		Wilson, James M. et al.
US 20050208730 A1	20050922	Methods of forming materials within openings, and methods of forming isolation regions	438/437	438/424	Moore, John T. et al.
US 20050201146 A1	20050915	Method of refreshing a PCRAM memory device	365/163		Moore, John T. et al.
US 20050192194 A1	20050901	Dissolving gel for cured polysulfide resins	510/188		Esposito, James R. et al.
US 20050180208 A1	20050818	Skewed sense AMP for variable resistance memory sensing	365/185.2		Hush, Glen et al.
US 20050177383 A1	20050811	Merit-based software licensing	705/1	705/8	Lin, Xiaofan et al.
US 20050177371 A1	20050811	Automated speech recognition	704/270.1		Yacoub, Sherif et al.
US 20050175167 A1	20050811	System and method for prioritizing contacts	379/265.13		Yacoub, Sherif et al.
US 20050171792 A1	20050804	System and method for language variation guided operator selection	705/1		Lin, Xiaofan et al.
US 20050169441 A1	20050804	System and method for extracting demographic information	379/88.16	379/88.02	Yacoub, Sherif et al.
US 20050167727 A1	20050804	Capacitors, methods of forming capacitors, and methods of forming capacitor dielectric layers	257/310	257/640; 257/E21.008; 257/E21.268; 438/250; 438/761	Moore, John T. et al.
US 20050167689 A1	20050804	Non-volatile zero field splitting resonance memory	257/100		Campbell, Kristy A. et al.

US 20050165796 A1	20050728	Method and system for managing image files in a hierarchical storage management system	707/100		Moore, John A.
US 20050157844 A1	20050721	Traveling X-ray inspection system with collimators	378/57		Bernardi, Richard T. et al.
US 20050157573 A1	20050721	Method of forming non-volatile resistance variable devices	365/200		Campbell, Kristy A. et al.
US 20050154531 A1	20050714	System and method for providing personalized weather reports and the like	702/3		Kelly, Terence F. et al.
US 20050151786 A1	20050714	Drop generating apparatus	347/42		Brookfield, John M. et al.
US 20050151783 A1	20050714	Drop generating apparatus	347/40		Brookfield, John M. et al.
US 20050150594 A1	20050714	Layered support and method for laminating CMP pads	156/307.7	156/289; 156/580	Kodaka, Ichiro et al.
US 20050148150 A1	20050707	Memory element and its method of formation	438/381	438/382	Moore, John T. et al.
US 20050146958 A1	20050707	Rewrite prevention in a variable resistance memory	365/203		Moore, John et al.
US 20050142289 A1	20050630	Polysulfide thermal vapour source for thin sulfide film deposition	427/248.1	204/192.1	Robert Stiles, James Alexander et al.
US 20050137103 A1	20050623	Stripper for cured negative-tone isoprene-based photoresist and bisbenzocyclobutene coatings	510/175	134/34; 510/407	Moore, John C.
US 20050136596 A1	20050623	Semiconductor constructions	438/261	257/E21.269; 257/E21.625	Moore, John T.
US	20050623	Chalcogenide glass	257/4	257/5;	Campbell,

20050133778 A1		constant current device, and its method of fabrication and operation		438/900	Kristy A. et al.
US 20050124155 A1	20050609	Electrode structures and method to form electrode structures that minimize electrode work function variation	438/654		Brooks, Joseph F. et al.
US 20050122757 A1	20050609	Memory architecture and method of manufacture and operation thereof	365/63		Moore, John T. et al.
US 20050116489 A1	20050602	Vehicle equipment console	296/37.8		Moore, John A.
US 20050108359 A1	20050519	Remote mail management system	709/217		Hyder, Robert et al.
US 20050108338 A1	20050519	Email application with user voice interface	709/206	715/727	Simske, Steven J. et al.
US 20050106635 A1	20050519	Compositions and methods for regulating thyroid hormone metabolism and cholesterol and lipid metabolism via the nuclear receptor car	435/7.2	514/567	Maglich, Jodi Marie et al.
US 20050106328 A1	20050519	Method for predicting and applying painting parameters and use thereof	427/421.1	427/8	Moore, John R. et al.
US 20050096840 A1	20050505	Navigation routing system and method	701/202	340/995.19; 701/209	Simske, Steven J.
US 20050089526 A1	20050428	Human immunodeficiency virus envelope glycoprotein mutants and uses thereof	424/188.1	530/395	Moore, John P. et al.
US 20050082731	20050421	Work piece holding arrangement	269/266		Moore, John et al.

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US 20050079241 A1	20050414	Method and apparatus for molding composite articles	425/388	425/147	Moore, John et al.
US 20050076295 A1	20050407	System and method of specifying image document layout definition	715/517		Simske, Steven J. et al.
US 20050073732 A1	20050407	Systems and methods for scanning media	358/527	358/1.2; 358/474	Benedicto, Jordi Arnabat et al.
US 20050073719 A1	20050407	Color image processor	358/1.18	358/1.2	Amela, Eduardo et al.
US 20050065789 A1	20050324	System and method with automated speech recognition engines	704/231		Yacoub, Sherif et al.
US 20050061552 A1	20050324	Rotary drill bit	175/385	175/403	Moore, John F.
US 20050054207 A1	20050310	Plasma etching methods and methods of forming memory devices comprising a chalcogenide comprising layer received operably proximate conductive electrodes	438/710	257/E21.241; 257/E21.268	Li, Li et al.
US 20050019699 A1	20050127	Non-volatile resistance variable device	430/311	257/E29.101; 257/E29.17; 257/E45.002	Moore, John T.
US 20050009366 A1	20050113	Adhesive support method for wafer coating, thinning and backside processing	438/782		Moore, John C.
US 20050007852 A1	20050113	Method of refreshing a PCRAM memory device	365/222		Moore, John T. et al.
US 20040264234 A1	20041230	PCRAM cell operation method to control on/off resistance variation	365/148		Moore, John T. et al.

US 20040263908 A1	20041230	Raster image path architecture	358/2.1	358/3.21; 382/173	Jacobs, William S. et al.
US 20040251299 A1	20041216	Secure window mailer and method of making	229/92.3		Moore, John A.
US 20040241759 A1	20041202	High throughput screening of libraries	435/7.2		Tozer, Eileen et al.
US 20040238958 A1	20041202	Electrode structure for use in an integrated circuit	257/751	257/E21.582; 257/E23.02; 257/E27.004; 257/E45.002	Moore, John T. et al.
US 20040238918 A1	20041202	Method of manufacture of a PCRAM memory cell	257/528	257/536; 438/238; 438/382	Moore, John T. et al.
US 20040236566 A1	20041125	System and method for identifying special word usage in a document	704/4		Simske, Steven J.
US 20040233728 A1	20041125	Chalcogenide glass constant current device, and its method of fabrication and operation	365/185.24		Campbell, Kristy A. et al.
US 20040232551 A1	20041125	Electrode structure for use in an integrated circuit	257/753	257/758; 257/E21.582; 257/E23.02; 257/E27.004; 257/E45.002; 438/622; 438/644	Moore, John T. et al.
US 20040229423 A1	20041118	Electrode structure for use in an integrated circuit	438/222	257/E21.582; 257/E23.02; 257/E27.004; 257/E45.002	Moore, John T. et al.
US 20040225531 A1	20041111	Computerized system and method for automated correlation of mammography report with pathology specimen result	705/2	378/37	Serrano, Laura Kathleen et al.
US 20040224308 A1	20041111	Stabilized viral envelope proteins and uses thereof	435/5	435/235.1; 435/366; 435/456; 435/69.3;	Binley, James M. et al.

				530/350; 536/23.72	
US 20040223393 A1	20041111	Skewed sense AMP for variable resistance memory sensing	365/208	365/190; 365/207	Hush, Glen et al.
US 20040223390 A1	20041111	Resistance variable memory element having chalcogenide glass for improved switching characteristics	365/202		Campbell, Kristy A. et al.
US 20040222441 A1	20041111	Global column select structure for accessing a memory	257/202		Moore, John T.
US 20040211957 A1	20041028	Method and apparatus for controlling metal doping of a chalcogenide memory element	257/42		Moore, John T. et al.
US 20040192006 A1	20040930	Layered resistance variable memory device and method of fabrication	438/382		Campbell, Kristy A. et al.
US 20040191961 A1	20040930	Method of forming non-volatile resistance variable devices and method of forming a programmable memory cell of memory circuitry	438/123	257/E45.002	Campbell, Kristy A. et al.
US 20040185728 A1	20040923	Textiles with high water release rates and methods for making same	442/79	156/279; 442/108; 442/173; 442/174; 442/93	Moore, John W. et al.
US 20040185625 A1	20040923	Graded GexSe100-x concentration in PCRAM	438/275	257/E45.002	Moore, John T. et al.
US 20040183144 A1	20040923	Plasma nitridization for adjusting transistor threshold voltage	257/411	257/E21.193	Beaman, Kevin L. et al.
US 20040183123	20040923	Gated semiconductor assemblies and	257/315	257/324; 257/E29.165;	Helm, Mark A. et al.

A1		methods of forming gated semiconductor assemblies		257/E29.302; 438/211; 438/216	
US 20040179390 A1	20040916	CHALCOGENIDE GLASS CONSTANT CURRENT DEVICE, AND ITS METHOD OF FABRICATION AND OPERATION	365/148		Campbell, Kristy A. et al.
US 20040178669 A1	20040916	Glide mount support base apparatus for child restraint car safety seat	297/250.1		Lady, Suzanne D. et al.
US 20040175859 A1	20040909	Single polarity programming of a PCRAM structure	438/102		Campbell, Kristy A. et al.
US 20040174900 A1	20040909	Method and system for providing broadband multimedia services	370/466	370/432	Volpi, John P. et al.
US 20040174443 A1	20040909	System and method for storing of records in a database	348/231.3	348/231.2	Simske, Steven J.
US 20040173861 A1	20040909	Transistor with nitrogen-hardened gate oxide	257/411	257/E21.193	Moore, John T.
US 20040171811 A1	20040902	Nonhuman pregnane x receptor sequences for use in comparative pharmacology	530/358	435/320.1; 435/325; 435/6; 435/69.1; 536/23.5	Kliewer, Steven Anthony et al.
US 20040171209 A1	20040902	Novel masked nitrogen enhanced gate oxide	438/239	257/E21.625	Moore, John T. et al.
US 20040171018 A1	20040902	Mouse farnesoid x receptor sequences for use in comparative pharmacology	435/6	435/320.1; 435/325; 435/69.1; 530/350; 536/23.5	Holt, Jason A. et al.
US 20040169387 A1	20040902	Vehicle equipment console	296/24.34		Moore, John A.
US 20040164336 A1	20040826	Films doped with carbon for use in integrated circuit	257/296	257/E21.274	Weimer, Ronald A. et al.

		technology			
US 20040164335 A1	20040826	Double sided container process used during the manufacture of a semiconductor device	257/296	257/E21.019; 257/E21.658	DeBoer, Scott J. et al.
US 20040161874 A1	20040819	Method of forming a non-volatile resistance variable device, and non-volatile resistance variable device	438/102	257/E27.071; 257/E45.002	Moore, John T. et al.
US 20040158820 A1	20040812	System for generating an application framework and components	717/136	717/101	Moore, John Wesley et al.
US 20040157417 A1	20040812	Methods to form a memory cell with metal-rich metal chalcogenide	438/510	257/E27.004; 257/E45.002; 438/128; 438/238	Moore, John T. et al.
US 20040157416 A1	20040812	Method of forming a non-volatile resistance variable device, and non-volatile resistance variable device	438/501	257/E21.006; 257/E27.071; 257/E45.002	Moore, John T. et al.
US 20040147069 A1	20040729	Semiconductor assemblies, methods of forming structures over semiconductor substrates, and methods of forming transistors associated with semiconductor substrates	438/197	438/287	Beaman, Kevin L. et al.
US 20040146806 A1	20040729	Photo-imageable nanocomposites	430/287.1	430/284.1; 430/285.1; 430/286.1; 430/306	Roberts, David H. et al.
US 20040141584 A1	20040722	HIGH ENERGY X-RAY MOBILE CARGO INSPECTION SYSTEM WITH PENUMBRA	378/57		Bernardi, Richard T. et al.

		COLLIMATOR			
US 20040133560 A1	20040708	Methods and systems for organizing electronic documents	707/3		Simske, Steven J.
US 20040124441 A1	20040701	Semiconductor wafer assemblies comprising photoresist over silicon nitride materials	257/200	257/E21.257; 257/E21.259; 257/E21.293	Moore, John T. et al.
US 20040124406 A1	20040701	Method of forming non-volatile resistance variable devices, method of forming a programmable memory cell of memory circuitry, and a non-volatile resistance variable device	257/4	257/E45.002	Campbell, Kristy A. et al.
US 20040124268 A1	20040701	Spray gun with internal mixing structure	239/398		Frazier, Keith et al.
US 20040121618 A1	20040624	Spin-on adhesive for temporary wafer coating and mounting to support wafer thinning and backside processing	438/782		Moore, John C.
US 20040102046 A1	20040527	Semiconductor processing method using photoresist and an antireflective coating	438/689	257/E21.029; 257/E21.232; 257/E21.577	Gilton, Terry L. et al.
US 20040095560 A1	20040520	Correction optics for flat-panel displays	353/79		Travis, Adrian Robert Leigh et al.
US 20040094813 A1	20040520	Methods of forming dielectric materials and methods of processing semiconductor substrates	257/411	257/406; 257/E21.193; 257/E21.268; 257/E21.293; 257/E29.165	Moore, John T.
US	20040506	Uses of a chemokine	424/208.1	424/130.1;	Allaway,

20040086528 A1		receptor for inhibiting HIV-1 infection		424/186.1; 424/204.1; 435/6; 435/91.1; 514/12	Graham P. et al.
US 20040074519 A1	20040422	Metal safe stabilized stripper for removing cured polymeric layers and negative tone acrylic photoresists	134/2	134/26; 510/176	Moore, John C.
US 20040071042 A1	20040415	PCRAM rewrite prevention	365/232		Moore, John et al.
US 20040064447 A1	20040401	System and method for management of synonymous searching	707/5		Simske, Steven J. et al.
US 20040064064 A1	20040401	Method and system for detecting the effects of alzheimer's disease in the human retina	600/558		Zhou, Qienyuan et al.
US 20040062104 A1	20040401	Semiconductor handler interface auto alignment	365/201		Muller, Luis A. et al.
US 20040053461 A1	20040318	Graded GexSe100-x concentration in PCRAM	438/225	257/E45.002	Moore, John T. et al.
US 20040051157 A1	20040318	Non-volatile resistance variable device	257/489	257/E29.101; 257/E29.17; 257/E45.002	Moore, John T.
US 20040049734 A1	20040311	System for and method of generating image annotation information	715/512		Simske, Steven J.
US 20040043585 A1	20040304	METHODS TO FORM A MEMORY CELL WITH METAL-RICH METAL CHALCOGENIDE	438/510	257/E27.004; 257/E45.002	Moore, John T. et al.
US 20040043245 A1	20040304	Method to control silver concentration in a resistance variable memory element	428/644	257/644	Moore, John T. et al.

US 20040042658 A1	20040304	Document analysis system and method	382/173		Simske, Steven J. et al.
US 20040042265 A1	20040304	Method and apparatus for controlling metal doping of a chalcogenide memory element	365/163		Moore, John T. et al.
US 20040042259 A1	20040304	Single polarity programming of a pcram structure	365/158	365/171; 365/173	Campbell, Kristy A. et al.
US 20040039466 A1	20040226	Method and apparatus for high speed data dumping and communication for a down hole tool	700/95		Lilly, Dave et al.
US 20040038480 A1	20040226	Method of manufacture of a PCRAM memory cell	438/257		Moore, John T. et al.
US 20040037470 A1	20040226	Systems and methods for processing text-based electronic documents	382/229		Simske, Steven J.
US 20040029351 A1	20040212	Methods of forming non-volatile resistance variable devices and methods of forming silver selenide comprising structures	438/382	257/E45.002	Gilton, Terry L. et al.
US 20040023457 A1	20040205	Global column select structure for accessing a memory	438/257		Moore, John T.
US 20040019385 A1	20040129	Manufacture of porous net-shaped materials comprising alpha or beta tricalcium phosphate or mixtures thereof	623/23.5		Ayers, Reed A. et al.
US 20040018560 A1	20040129	Crystallized LXR polypeptide in complex with a ligand and screening methods employing same	435/7.1	530/350; 702/19	Bledsoe, Randy K. et al.

US 20040017941 A1	20040129	System and method for bounding and classifying regions within a graphical image	382/180		Simske, Steven J.
US 20040015775 A1	20040122	Systems and methods for improved accuracy of extracted digital content	715/500		Simske, Steven J. et al.
US 20040013906 A1	20040122	Oxygen substituted barium thioaluminate phosphor materials	428/690	252/301.4S; 313/503; 313/509; 428/917	Stiles, James Alexander Robert et al.
US 20040013318 A1	20040122	System and method for manipulating a skewed digital image	382/289		Simske, Steven J. et al.
US 20040008884 A1	20040115	System and method for scanned image bleedthrough processing	382/165	382/170; 382/173	Simske, Steven John et al.
US 20040002851 A1	20040101	System and method of automatic personalization of computer users' computing experience	704/9		Simske, Steven J.
US 20030223637 A1	20031204	System and method of locating a non- textual region of an electronic document or image that matches a user-defined description of the region	382/176		Simske, Steve John et al.
US 20030222280 A1	20031204	Apparatus and method for dual cell common electrode PCRAM memory device	257/200		Moore, John
US 20030210249 A1	20031113	System and method of automatic data checking and correction	345/581		Simske, Steven J.
US 20030209778 A1	20031113	CAPACITORS	257/532	257/528; 257/E21.008; 257/E21.268	Moore, John T. et al.

US 20030207592 A1	20031106	Method of forming a capacitor dielectric layer	438/775	257/E21.008; 257/E21.268; 438/776; 438/777	Moore, John T. et al.
US 20030206182 A1	20031106	Synchronized graphical information and time-lapse photography for weather presentations and the like	345/632		Kelly, Terence F. et al.
US 20030187617 A1	20031002	User perception tool	702/186		Murphy, Stephen F. et al.
US 20030185036 A1	20031002	Method for programming a memory cell	365/100		Gilton, Terry L. et al.
US 20030175622 A1	20030918	High performance, photoimageable resin compositions and printing plates prepared therefrom	430/285.1	430/281.1; 430/283.1; 430/284.1; 430/286.1; 430/287.1; 430/306; 522/100; 522/102; 522/103; 522/110; 522/95	Hu, Yuxin et al.
US 20030169625 A1	20030911	Programmable conductor random access memory and method for sensing same	365/189.07		Hush, Glen et al.
US 20030160242 A1	20030828	DRAM cell constructions	257/68	257/E21.65	Gonzalez, Fernando et al.
US 20030156468 A1	20030821	Resistance variable 'on' memory	365/200	257/E45.002	Campbell, Kristy A. et al.
US 20030155606 A1	20030821	Method to alter chalcogenide glass for improved switching characteristics	257/314		Campbell, Kristy A. et al.
US 20030155589 A1	20030821	Silver-selenide/chalcogenide glass stack for	257/225		Campbell, Kristy A. et al.

		resistance variable memory			
US 20030154321 A1	20030814	Method and system for registering a control within an operating environment using a control manager	719/320		Wyke, Kenneth C. et al.
US 20030153190 A1	20030814	Semiconductor processing method using photoresist and an antireflective coating	438/694	257/E21.029; 257/E21.232; 257/E21.577	Gilton, Terry L. et al.
US 20030153166 A1	20030814	Transistor and method of making the same	438/484	257/E21.193	Moore, John T.
US 20030148904 A1	20030807	Cured polymers dissolving compositions	510/201	134/26; 134/4; 257/E21.255; 510/219	Moore, John C.
US 20030143782 A1	20030731	METHODS OF FORMING GERMANIUM SELENIDE COMPRISING DEVICES AND METHODS OF FORMING SILVER SELENIDE COMPRISING STRUCTURES	438/128	257/E45.002	Gilton, Terry L. et al.
US 20030128612 A1	20030710	PCRAM rewrite prevention	365/222	365/149; 365/150	Moore, John et al.
US 20030125594 A1	20030703	Catalyst formulation comprising ceramic foam material	585/520	422/131; 422/211; 502/178; 502/412; 585/510	Moore, John H.
US 20030120698 A1	20030626	Manager for software controls in an operating environment	718/100		Wyke, Kenneth C. et al.
US 20030120697 A1	20030626	System and method for adapting a software control in an	718/100		Wyke, Kenneth C. et al.

		operating environment			
US 20030119563 A1	20030626	Electronic interactive communication system and the method therefor	455/566		Wyke, Kenneth C. et al.
US 20030117438 A1	20030626	System and method for manipulating data using a control	715/764		Wyke, Kenneth C. et al.
US 20030096497 A1	20030522	Electrode structure for use in an integrated circuit	438/652 257/E21.582; 257/E23.02; 257/E27.004; 257/E45.002; 438/658; 438/660; 438/666		Moore, John T. et al.
US 20030085436 A1	20030508	Method of forming low dielectric silicon oxynitride spacer films highly selective to etchants	257/408 257/E21.268; 257/E21.269; 257/E21.507; 438/303; 438/595		Moore, John T.
US 20030084824 A1	20030508	Process for producing building materials from raw paint sludge	106/739	106/277	Matheson, Robert R. et al.
US 20030074081 A1	20030417	Non-uniform porosity tissue implant	623/23.5	623/23.76	Ayers, Reed A.
US 20030068855 A1	20030410	Method for forming protective films and spacers	438/216	257/E21.507	Moore, John T.
US 20030067183 A1	20030410	Vehicle equipment console	296/24.34		Moore, John A.
US 20030063703 A1	20030403	Computed tomography with virtual tilt and angulation	378/17	378/15	Moore, John F.
US 20030061832 A1	20030403	Combustion synthesis of glass (Al ₂ O ₃ -CaO-X-Y) ceramic (TiB ₂) composites	65/17.4		Yi, Hu Chun et al.
US 20030057514 A1	20030327	INTEGRATED CIRCUIT FORMED BY REMOVING UNDESIRABLE SECOND OXIDE	257/507 257/E21.251; 257/E21.268; 257/E21.552		Chapek, David L. et al.

		WHILE MINIMALLY AFFECTING A DESIRABLE FIRST OXIDE			
US 20030052839 A1	20030320	Stabilized viral envelope proteins and uses thereof	345/41		Binley, James M. et al.
US 20030050757 A1	20030313	System and method for processing weather information	702/3		Moore, John S.
US 20030049912 A1	20030313	METHOD OF FORMING CHALCOGENIDE COMPRISING DEVICES AND METHOD OF FORMING A PROGRAMMABLE MEMORY CELL OF MEMORY CIRCUITY	438/385	257/E45.002; 365/225.7; 438/102; 438/131	Campbell, Kristy A. et al.
US 20030046710 A1	20030306	Multi-media communication system for the disabled and others	725/133	725/110	Moore, John F.
US 20030045054 A1	20030306	Method of forming non-volatile resistance variable devices, method of forming a programmable memory cell of memory circuitry, and a non-volatile resistance variable device	438/257	257/E45.002; 365/182	Campbell, Kristy A. et al.
US 20030045050 A1	20030306	Capacitors, methods of forming capacitors, and methods of forming capacitor dielectric layers	438/239	257/296; 257/E21.008; 257/E21.268; 438/381	Moore, John T. et al.
US 20030045049 A1	20030306	Method of forming chalcogenide comprising devices	438/237		Campbell, Kristy A. et al.

US 20030038301 A1	20030227	Apparatus and method for dual cell common electrode PCRAM memory device	257/200		Moore, John
US 20030027416 A1	20030206	METHOD OF FORMING INTEGRATED CIRCUITRY, METHOD OF FORMING MEMORY CIRCUITRY, AND METHOD OF FORMING RANDOM ACCESS MEMORY CIRCUITRY	438/618	257/E21.582; 257/E21.645; 257/E27.081	Moore, John T.
US 20030020108 A1	20030130	Films doped with carbon for use in integrated circuit technology	257/296	257/E21.274	Weimer, Ronald A. et al.
US 20030003655 A1	20030102	Methods of forming DRAM cells	438/253	257/E21.65	Gonzalez, Fernando et al.
US 20030001229 A1	20030102	Chalcogenide comprising device	257/528	257/536; 257/E27.071; 257/E45.002; 438/381; 438/510; 438/518; 438/535	Moore, John T. et al.
US 20020196479 A1	20021226	System and method of automated scan workflow assignment	358/474	358/527	Simske, Steven J.
US 20020182812 A1	20021205	Transistor structures, methods of incorporating nitrogen into silicon-oxide-containing layers; and methods of forming transistors	438/287	257/E21.193; 257/E29.162	Sandhu, Gurtej S. et al.
US 20020182811 A1	20021205	Novel masked nitrogen enhanced gate oxide	438/287	257/E21.625; 438/770	Moore, John T. et al.
US	20021121	High performance,	430/18	430/284.1;	Hu, Yuxin

20020172875 A1		photoimageable resin compositions and printing plates prepared therefrom		522/95	et al.
US 20020168830 A1	20021114	Double sided container process used during the manufacture of a semiconductor device	438/396	257/E21.019; 257/E21.658; 438/253	DeBoer, Scott J. et al.
US 20020151191 A1	20021017	Semiconductor processing methods of transferring patterns from patterned Photoresists to materials, and structures comprising silicon nitride	438/791	257/E21.206; 257/E21.269	DeBoer, Scott Jeffrey et al.
US 20020151180 A1	20021017	Semiconductor processing methods of transferring patterns from patterned photoresists to materials, and structures comprising silicon nitride	438/703	257/E21.206; 257/E21.269; 438/791	DeBoer, Scott Jeffrey et al.
US 20020151160 A1	20021017	Semiconductor processing methods of transferring patterns from patterned photoresists to materials, and structures comprising silicon nitride	438/585	257/E21.206; 257/E21.269; 438/744	DeBoer, Scott Jeffrey et al.
US 20020146910 A1	20021010	Semiconductor processing methods of transferring patterns from patterned photoresists to materials, and structures comprising silicon nitride	438/724	257/E21.206; 257/E21.269; 438/791	DeBoer, Scott Jeffrey et al.
US 20020145615 A1	20021010	Layered image rendering	345/629		Moore, John S.
US 20020132483	20020919	Methods of forming materials within	438/692	257/E21.244; 257/E21.55	Moore, John T. et

A1		openings, and methods of forming isolation regions			al.
US 20020127886 A1	20020912	Method to manufacture a buried electrode PCRAM cell	438/800	257/E45.002	Moore, John T. et al.
US 20020123248 A1	20020905	METHODS OF METAL DOPING A CHALCOGENIDE MATERIAL	438/795	257/E21.006; 257/E27.071; 257/E45.002	Moore, John T. et al.
US 20020123170 A1	20020905	PCRAM cell manufacturing	438/102	257/E45.002; 438/103	Moore, John T. et al.
US 20020123169 A1	20020905	Methods of forming non-volatile resistance variable devices, and non-volatile resistance variable devices	438/95	257/E21.006; 257/E27.071; 257/E45.002	Moore, John T. et al.
US 20020117709 A1	20020829	Use of dilute steam ambient for improvement of flash devices	257/315	257/E21.209; 257/E29.165	Weimer, Ronald A. et al.
US 20020113979 A1	20020822	System and method for scan-to-print architecture	358/1.6	358/1.15	Rahgozar, M. Armoh et al.
US 20020111039 A1	20020815	Method of forming low dielectric silicon oxynitride spacer films highly selective to etchants	438/778	257/499; 257/506; 257/E21.268; 257/E21.269; 257/E21.507; 438/791; 438/794	Moore, John T.
US 20020109870 A1	20020815	System and method for scan-to- print architecture	358/504	358/531	Moore, John A. et al.
US 20020109199 A1	20020815	Transistor devices	257/411	257/406; 257/410; 257/E21.193; 257/E21.268; 257/E21.293; 257/E29.165	Moore, John T.
US 20020106896 A1	20020808	Batch processing for semiconductor wafers to form aluminum	438/688	257/E21.029; 257/E21.035; 257/E21.168;	Kraus, Brenda D. et al.

		nitride and titanium aluminum nitride		257/E21.17; 257/E21.292; 257/E21.576	
US 20020106849 A1	20020808	Method of forming non-volatile resistance variable devices, method of precluding diffusion of a metal into adjacent chalcogenide material, and non-volatile resistance variable devices	438/213	257/E29.101; 257/E29.17; 257/E45.002	Moore, John T.
US 20020098710 A1	20020725	Methods Of Forming Transistors	438/732	257/E21.193; 257/E29.162	Sandhu, Gurtej S. et al.
US 20020094621 A1	20020718	Methods of forming a nitrogen enriched region	438/197	257/E21.193; 257/E29.162	Sandhu, Gurtej S. et al.
US 20020094620 A1	20020718	Transistor Structures	438/197	257/E21.193; 257/E29.162	Sandhu, Gurtej S. et al.
US 20020074576 A1	20020620	Semiconductor assemblies, methods of forming structures over semiconductor substrates, and methods of forming transistors associated with semiconductor substrates	257/213		Beaman, Kevin L. et al.
US 20020067375 A1	20020606	Goal-oriented design for the printer property's graphical user interface	715/776		Moore, John Anthony et al.
US 20020062154 A1	20020523	Non-uniform porosity tissue implant	623/23.76	623/16.11	Ayers, Reed A.
US 20020061624 A1	20020523	Transistor and method of making the same	438/268	257/E21.193	Moore, John T.
US 20020055225 A1	20020509	DRAM cell constructions	438/253	257/E21.65	Gonzalez, Fernando et al.
US	20020509	Transistor and	257/325	257/E21.193	Moore,

20020053693 A1		method of making the same			John T.
US 20020047202 A1	20020425	Semiconductor wafer assemblies comprising photoresist over silicon nitride materials	257/751	257/E21.257; 257/E21.259; 257/E21.293	Moore, John T. et al.
US 20020047142 A1	20020425	STRUCTURES COMPRISING SILICON NITRIDE	257/288	257/E21.206; 257/E21.269 CIPG 20060101 A H01L H01L21/02 F I R US M 20060101 CIPC H01L CIPP H01L21/02 20060101 CIPG 20060101 A H01L H01L21/28 L I R US M 20060101 CIPC H01L CIPS H01L21/28 20060101	DeBoer, Scott Jeffrey et al.
US 20020032114 A1	20020314	Combustion synthesis of glass (Al ₂ O ₃ -B ₂ O ₃ -MgO) ceramic (Tib ₂) composites	501/32	501/10; 501/39	Yi, Hu Chun et al.
US 20020019622 A1	20020214	CONTAINER CAP ASSEMBLY HAVING AN ENCLOSED PENETRATOR	604/411	141/329; 215/247; 604/415	DAUBERT, RICHARD F. et al.
US 20020019142 A1	20020214	Methods of forming transistors associated with semiconductor substrates	438/765	257/E21.269; 257/E21.625	Moore, John T.
US 20020006736 A1	20020117	Methods of forming transistors associated with semiconductor	438/765	257/E21.269; 257/E21.625	Moore, John T.

		substrates			
US 20020001897 A1	20020103	METHODS OF FORMING GATED SEMICONDUCTOR ASSEMBLIES	438/201	257/E29.165; 257/E29.302	HELM, MARK A. et al.
US 20010049198 A1	20011206	Methods of forming materials within openings, and methods of forming isolation regions	438/689	257/E21.244; 257/E21.55	Moore, John T. et al.
US 20010044218 A1	20011122	SEMICONDUCTOR PROCESSING METHODS OF FORMING PHOTORESIST OVER SILICON NITRIDE MATERIALS	438/763	257/E21.257; 257/E21.259; 438/782; 438/791	MOORE, JOHN T. et al.
US 20010042884 A1	20011122	GATED SEMICONDUCTOR ASSEMBLIES	257/324	257/E29.165; 257/E29.302	HELM, MARK A. et al.
US 20010034129 A1	20011025	Capacitor constructions, DRAM constructions, semiconductive material assemblies, etching processes, and methods for forming capacitors and DRAMs	438/689	257/E21.008; 257/E21.27	Moore, John T. et al.
US 20010017401 A1	20010830	Method and apparatus for endpointing planarization of a microelectronic substrate	257/635	257/634; 257/915; 257/E21.244	Moore, John T.
US 20010014521 A1	20010816	Batch processing for semiconductor wafers to form aluminum nitride and titanium aluminum nitride	438/586	257/E21.029; 257/E21.035; 257/E21.168; 257/E21.17; 257/E21.292; 257/E21.576	Kraus, Brenda D. et al.
US 20010004543 A1	20010621	Semiconductor processing method and trench isolation	438/402	257/E21.318; 257/E21.546; 438/424;	Moore, John T.

		method		438/473	
US 20010001116 A1	20010510	Container cap assembly having an enclosed penetrator	604/200	215/296	Daubert, Richard F. et al.
US 20010000794 A1	20010503	Container cap assembly having an enclosed penetrator	604/200	222/80	Daubert, Richard F. et al.
US 20010000793 A1	20010503	Container cap assembly having an enclosed penetrator	604/200	222/80	Daubert, Richard F. et al.
US 7005409 B2	20060228	Dissolving gel for cured polysulfide resins	510/212	510/175; 510/201; 510/245; 510/254; 510/499; 510/500; 510/501	Esposito; James R. et al.
US 6998697 B2	20060214	Non-volatile resistance variable devices	257/529	257/136; 257/2; 257/296; 257/3; 257/4; 257/5; 257/508; 257/530; 257/536; 257/537; 257/613; 257/614; 257/616; 257/78; 365/129; 365/148; 365/163; 365/171; 365/182; 438/257	Campbell; Kristy A. et al.
US 6988995 B2	20060124	Method and system for detecting the effects of Alzheimer's disease in the human retina	600/558	356/484	Zhou; Qiényuan et al.
US 6980332 B2	20051227	System and method of automated scan workflow assignment	358/445	358/446; 358/447; 358/461; 358/463; 358/475;	Simske; Steven J.

				358/504; 358/509; 382/270; 382/273	
US 6969146 B2	20051129	Drop generating apparatus	347/40	347/43; 347/68	Brookfield; John M. et al.
US 6967383 B2	20051122	Transistor with nitrogen-hardened gate oxide	257/410	257/411; 438/474; 438/761; 438/763	Moore; John T.
US 6963413 B2	20051108	System and method for scan-to-print architecture	358/1.13	382/217; 715/505; 715/506; 715/908	Rahgozar; M. Armon et al.
US 6963101 B2	20051108	Films doped with carbon for use in integrated circuit technology	257/306	257/296; 257/309	Weimer; Ronald A. et al.
US 6961277 B2	20051101	Method of refreshing a PCRAM memory device	365/222	365/185.18; 365/185.25; 365/226	Moore; John T. et al.
US 6961140 B2	20051101	System and method for scan-to-print architecture	358/1.15	358/1.18; 358/1.6; 358/3.27; 358/406	Moore; John A. et al.
US 6961061 B1	20051101	Forecast weather video presentation system and method	345/473	345/634; 702/3	Johnson; Chad W. et al.
US 6955940 B2	20051018	Method of forming chalcogenide comprising devices	438/95	438/795	Campbell; Kristy A. et al.
US 6953720 B2	20051011	Methods for forming chalcogenide glass-based memory elements	438/238	257/E45.002; 438/29; 438/381	Moore; John T. et al.
US 6951805 B2	20051004	Method of forming integrated circuitry, method of forming memory circuitry, and method of forming random access memory circuitry	438/618	257/E21.582; 257/E21.645; 257/E27.081; 438/637; 438/667	Moore; John T.
US 6951791 B2	20051004	Global column select structure for	438/257	438/453	Moore; John T.

		accessing a memory			
US 6949789 B2	20050927	Use of dilute steam ambient for improvement of flash devices	257/315	257/321; 257/325; 257/E21.209; 257/E29.165	Weimer; Ronald A. et al.
US 6949402 B2	20050927	Method of forming a non-volatile resistance variable device	438/95	257/E27.071; 257/E45.002; 438/102	Moore; John T. et al.
US 6937528 B2	20050830	Variable resistance memory and method for sensing same	365/189.07	365/203	Hush; Glen et al.
US 6930909 B2	20050816	Memory device and methods of controlling resistance variation and resistance profile drift	365/148	365/158; 365/189.07	Moore; John T. et al.
US 6918391 B1	20050719	Multi-lumen endotracheal tube	128/842	128/207.14; 128/207.15; 128/911; 600/116; 600/120; 600/158	Moore; Johnny V.
US 6912147 B2	20050628	Chalcogenide glass constant current device, and its method of fabrication and operation	365/113	365/148; 365/163	Campbell; Kristy A. et al.
US 6909656 B2	20050621	PCRAM rewrite prevention	365/222	365/203	Moore; John et al.
US 6894304 B2	20050517	Apparatus and method for dual cell common electrode PCRAM memory device	257/4	257/2; 257/295; 257/3; 257/310; 257/5; 257/758	Moore; John
US 6891749 B2	20050510	Resistance variable 'on' memory	365/163	257/2; 257/E45.002; 365/100; 365/113; 365/114; 365/148	Campbell; Kristy A. et al.
US 6891245 B2	20050510	Integrated circuit formed by removing undesirable second	257/506	257/510; 257/E21.251; 257/E21.268;	Chapek; David L. et al.

		oxide while minimally affecting a desirable first oxide		257/E21.552	
US 6891215 B2	20050510	Capacitors	257/298	257/239; 257/299; 257/300; 257/301; 257/302; 257/303; 257/304; 257/305; 257/306; 257/307; 257/308; 257/309; 257/310; 257/311; 257/312; 257/313; 257/E21.008; 257/E21.268	Moore; John T. et al.
US 6890878 B2	20050510	Catalyst formulation comprising ceramic foam material	502/439	428/312.2; 428/312.6; 428/313.3; 428/317.9; 501/1; 501/154; 501/80; 501/88; 502/178; 502/208; 502/214; 502/232; 502/412; 502/527.14; 502/527.16; 502/527.24	Moore; John H.□
US 6888771 B2	20050503	Skewed sense AMP for variable resistance memory sensing	365/208	365/190; 365/207	Hush; Glen et al.
US 6884725 B2	20050426	Methods of forming materials within openings, and methods of forming isolation regions	438/692	257/E21.244; 257/E21.55; 438/700; 438/723; 438/724	Moore; John T. et al.
US 6882578	20050419	PCRAM rewrite	365/189.01	365/203;	Moore;

B2		prevention		365/207	John et al.
US 6881623 B2	20050419	Method of forming chalcogenide comprising devices, method of forming a programmable memory cell of memory circuitry, and a chalcogenide comprising device	438/257	257/E45.002; 365/129; 365/132; 365/135; 365/140; 365/170; 365/180; 365/188	Campbell; Kristy A. et al.
US 6880122 B1	20050412	Segmenting a document into regions associated with a data type, and assigning pipelines to process such regions	715/500	382/176; 715/520; 715/521	Lee; Jeffrey P et al.
US 6878585 B2	20050412	Methods of forming capacitors	438/253	257/E21.008; 257/E21.268; 438/396; 438/703; 438/757; 438/761; 438/775; 438/791	Moore; John T. et al.
US 6875707 B2	20050405	Method of forming a capacitor dielectric layer	438/775	257/E21.008; 257/E21.268	Moore; John T. et al.
US 6869894 B2	20050322	Spin-on adhesive for temporary wafer coating and mounting to support wafer thinning and backside processing	438/782	156/331.7; 156/332	Moore; John C.
US 6867996 B2	20050315	Single-polarity programmable resistance-variable memory element	365/100	365/148; 365/163	Campbell; Kristy A. et al.
US 6867114 B2	20050315	Methods to form a memory cell with metal-rich metal chalcogenide	438/510	257/E27.004; 257/E45.002; 438/770	Moore; John T. et al.
US 6867064 B2	20050315	Method to alter chalcogenide glass for improved switching characteristics	438/95	438/102; 438/308; 438/795	Campbell; Kristy A. et al.

US 6864521 B2	20050308	Method to control silver concentration in a resistance variable memory element	257/296	257/4; 257/489; 257/508; 257/750; 257/751; 257/761; 257/762 CIPG 20060101 A C23C C23C14/06 L I R US M 20060101 CICL C23C CIPS C23C14/06 20060101 CIPG 20060101 A C23C C23C14/06 L I R US M 20060101 CICL C23C CIPS C23C14/06 20060101 CIPG 20060101 A C23C C23C16/30 L I R US M 20060101 CICL C23C CIPS C23C16/30; 20060101 CIPG 20060101 A C23C C23C16/30 L I R US M 20060101 CICL C23C CIPS C23C16/30	Moore; John T. et al.
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US 6861367 B2	20050301	Semiconductor processing method using photoresist and an antireflective coating	438/737	257/E21.029; 257/E21.232; 257/E21.577; 438/725; 438/736; 438/745	Gilton; Terry L. et al.
US 6858523 B2	20050222	Semiconductor processing methods of transferring patterns from patterned photoresists to materials, and structures comprising silicon nitride	438/585	257/E21.206; 257/E21.269; 438/595 CIPG 20060101 A H01L H01L21/02 L I R US M 20060101 CICL H01L CIPS H01L21/02 20060101 CIPG 20060101 A H01L H01L21/28 L I R US M 20060101 CICL H01L CIPS H01L21/28 20060101	DeBoer; Scott Jeffrey et al.
US 6857722 B1	20050222	Drop generating apparatus	347/40		Greiser; Christine M. et al.
US 6856943 B2	20050215	User perception tool	702/186	702/122; 702/187; 702/188; 709/224; 711/113; 717/106	Murphy; Stephen F et al.
US 6856323 B2	20050215	Layered image rendering	345/629	345/632; 345/633; 345/634; 345/639; 345/640	Moore; John S.
US 6856002 B2	20050215	Graded GexSe100-x concentration in	257/529	257/296; 257/528;	Moore; John T. et

		PCRAM		257/536; 257/55; 257/63; 257/E45.002	al.
US 6833559 B2	20041221	Non-volatile resistance variable device	257/52	257/245; 257/246; 257/49; 257/E29.101; 257/E29.17; 257/E45.002; 438/102; 438/292; 438/652; 438/653 CIPG 20060101 A H01C H01C17/075 L I R US M 20060101 CICL H01C CIPS H01C17/075 20060101 CIPG 20060101 A H01C H01C17/075 L I R US M 20060101 CICL H01C CIPS H01C17/075 20060101 CIPG 20060101 A H01C H01C17/28 L I R US M 20060101 CICL H01C CIPS; H01C17/28 20060101 CIPG 20060101 A	Moore; John T.

				H01C H01C17/28 L I R US M 20060101 CICL H01C CIPS H01C17/28 20060101 CIPG 20060101 A H01L H01L29/02 L I R US M 20060101 CICL H01L CIPS H01L29/02 20060101 CIPG 20060101 A H01L H01L29/24 L I R US M 20060101 CICL H01L CIPS; H01L29/24 20060101 CIPG 20060101 A H01L H01L29/66 L I R US M 20060101 CICL H01L CIPS H01L29/66 20060101 CIPG 20060101 A H01L H01L29/68 L I R US M 20060101 CICL H01L CIPS	
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US 6833329 B1	20041221	Methods of forming oxide regions over semiconductor substrates	438/770	257/E21.269; 257/E21.625; 438/176; 438/275; 438/762; 438/769; 438/787	Moore; John T.
US 6831019 B1	20041214	Plasma etching methods and methods of forming memory devices comprising a chalcogenide comprising layer received operably proximate conductive electrodes	438/714	257/E21.241; 257/E21.268; 438/709; 438/723; 438/725; 438/743	Li; Li et al.
US 6829536 B2	20041207	System and method for processing weather information	702/3	73/170.16	Moore; John S.
US 6823263 B1	20041123	System and method for providing personalized weather reports and the like	702/3		Kelly; Terence F. et al.
US 6818608	20041116	Cured polymers	510/321	257/E21.255;	Moore;

B2		dissolving compositions		510/224; 510/303; 510/374; 510/445; 510/499	John C.
US 6818481 B2	20041116	Method to manufacture a buried electrode PCRAM cell	438/130	257/E45.002; 438/768; 438/800; 438/95	Moore; John T. et al.
US 6815818 B2	20041109	Electrode structure for use in an integrated circuit	257/751	257/753; 257/762; 257/766; 257/774; 257/E21.582; 257/E23.02; 257/E27.004; 257/E45.002	Moore; John T. et al.
US 6815375 B2	20041109	Methods of forming dielectric materials and methods of processing semiconductor substrates	438/792	257/E21.193; 257/E21.268; 257/E21.293; 257/E29.165; 438/261; 438/769; 438/775; 438/791	Moore; John T.
US 6813178 B2	20041102	Chalcogenide glass constant current device, and its method of fabrication and operation	365/148	365/113; 365/45	Campbell; Kristy A. et al.
US 6812087 B2	20041102	Methods of forming non-volatile resistance variable devices and methods of forming silver selenide comprising structures	438/238	257/E45.002; 438/650; 438/672	Giltom; Terry L. et al.
US 6811096 B2	20041102	Spray gun with internal mixing structure	239/398	137/896; 239/407; 239/413	Frazier; Keith et al.
US 6806175 B2	20041019	Method for forming protective films and spacers	438/595	257/E21.507; 438/724; 438/744; 438/757; 438/791 CIPG	Moore; John T.

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US 6799830 B1	20041005	Drop generating apparatus	347/40		Brookfield; John M. et al.
US 6785357 B2	20040831	High energy X-ray mobile cargo inspection system with penumbra collimator	378/57	378/193; 378/196	Bernardi; Richard T. et al.
US 6784018 B2	20040831	Method of forming chalcogenide comprising devices and method of forming a programmable memory cell of memory circuitry	438/102	257/E45.002; 438/103; 438/308; 438/522; 438/537; 438/558; 438/84	Campbell; Kristy A. et al.
US 6780566 B2	20040824	High performance, photoimageable resin compositions and printing plates prepared therefrom	430/284.1	430/306; 522/95	Hu; Yuxin et al.
US 6777290 B2	20040817	Global column select structure for	438/257	438/405; 438/453	Moore; John T.

		accessing a memory			
US 6774418 B2	20040810	Low dielectric silicon oxynitride spacer films and devices incorporating such films	257/288	257/336; 257/344; 257/351; 257/411; 257/E21.268; 257/E21.269; 257/E21.507	Moore; John T.
US 6756634 B2	20040629	Gated semiconductor assemblies	257/324	257/410; 257/411; 257/E29.165; 257/E29.302	Helm; Mark A. et al.
US 6751114 B2	20040615	Method for programming a memory cell	365/100	365/185.24	Gilton; Terry L. et al.
US 6747327 B2	20040608	Transistor with nitrogen hardened gate oxide	257/410	257/411; 257/E21.193; 438/474; 438/761; 438/763	Moore; John T.
US 6744098 B2	20040601	Transistor devices	257/324	257/288; 257/325; 257/326; 257/E21.193; 257/E21.268; 257/E21.293; 257/E29.165	Moore; John T.
US 6737312 B2	20040518	Method of fabricating dual PCRAM cells sharing a common electrode	438/238	438/102; 438/381; 438/95	Moore; John
US 6734062 B2	20040511	Methods of forming DRAM cells	438/253	257/E21.65; 438/396	Gonzalez; Fernando et al.
US 6727192 B2	20040427	Methods of metal doping a chalcogenide material	438/795	257/E21.006; 257/E27.071; 257/E45.002	Moore; John T. et al.
US 6717115 B1	20040406	Semiconductor handler for rapid testing	219/444.1	118/724	Pfahnl; Andreas C. et al.
US 6713807 B2	20040330	Films doped with carbon for use in integrated circuit technology	257/306	257/900; 257/E21.274	Weimer; Ronald A. et al.
US 6711409 B1	20040323	Node belonging to multiple clusters in	455/445	370/242; 370/335;	Zavgren, Jr.; John R.

		an ad hoc wireless network		455/11.1; 455/13.1; 455/571	et al.
US 6710423 B2	20040323	Chalcogenide comprising device	257/528	257/E27.071; 257/E45.002	Moore; John T. et al.
US 6710173 B1	20040323	Stabilized viral envelope proteins and uses thereof	536/23.72	424/188.1; 424/208.1	Binley; James M. et al.
US 6709956 B2	20040323	Transistor and method of making the same	438/484	257/E21.193; 438/761; 438/763; 438/775	Moore; John T.
US 6709887 B2	20040323	Method of forming a chalcogenide comprising device	438/95	257/E21.006; 257/E27.071; 257/E45.002	Moore; John T. et al.
US 6707090 B2	20040316	DRAM cell constructions	257/296	257/401; 257/906; 257/E21.65	Gonzalez; Fernando et al.
US 6704033 B2	20040309	Goal-oriented design for the printer property's graphical user interface	715/777	715/715	Moore; John Anthony et al.
US 6699743 B2	20040302	Masked nitrogen enhanced gate oxide	438/216	257/E21.625; 438/275; 438/287; 438/591	Moore; John T. et al.
US 6696336 B2	20040224	Double sided container process used during the manufacture of a semiconductor device	438/253	257/E21.019; 257/E21.658; 438/254; 438/396; 438/397	DeBoer; Scott J. et al.
US 6693345 B2	20040217	Semiconductor wafer assemblies comprising photoresist over silicon nitride materials	257/640	257/629; 257/632; 257/639; 257/E21.257; 257/E21.259; 257/E21.293	Moore; John T. et al.
US 6690046 B2	20040210	Semiconductor assemblies, methods of forming structures over semiconductor substrates, and methods of forming transistors associated with semiconductor	257/288	257/401; 257/900	Beaman; Kevin L. et al.

		substrates			
US 6686298 B1	20040203	Methods of forming structures over semiconductor substrates, and methods of forming transistors associated with semiconductor substrates	438/775	438/787	Beaman; Kevin L. et al.
US 6683984 B1	20040127	Digital imaging device with background training	382/190	382/199; 382/276; 382/278	Simske; Steven J et al.
US 6683935 B2	20040127	Computed tomography with virtual tilt and angulation	378/17		Moore; John F.
US 6682979 B2	20040127	Methods of forming transistors associated with semiconductor substrates	438/275	257/E21.269; 257/E21.625; 438/287; 438/591; 438/770; 438/775; 438/776	Moore; John T.
US 6677661 B1	20040113	Semiconductive wafer assemblies	257/649	257/640; 257/E21.029; 257/E21.206; 257/E21.257; 257/E21.293	DeBoer; Scott Jeffrey et al.
US 6674901 B1	20040106	Document analysis system and method	382/180	358/453; 382/282; 382/299	Simske; Steven J et al.
US 6670288 B1	20031230	Methods of forming a layer of silicon nitride in a semiconductor fabrication process	438/791	257/E21.029; 257/E21.206; 257/E21.257; 257/E21.293; 438/483; 438/520	DeBoer; Scott Jeffrey et al.
US 6662186 B1	20031209	System and method for a data propagation file format	707/101	707/203; 715/511; 715/523; 717/122	Esquibel; Daniel M et al.
US 6660658 B2	20031209	Transistor structures, methods of incorporating nitrogen into silicon-oxide-containing	438/775	257/E21.193; 257/E29.162; 438/776; 438/777	Sandhu; Gurtej S. et al.

		layers; and methods of forming transistors			
US 6660657 B1	20031209	Methods of incorporating nitrogen into silicon-oxide-containing layers	438/775	257/E21.193; 257/E29.162; 438/776; 438/777	Sandhu; Gurtej S. et al.
US 6654955 B1	20031125	Adding speech recognition libraries to an existing program at runtime	717/163	704/231; 704/275	Kusnitz; Jeffrey Alan et al.
US 6653184 B2	20031125	Method of forming transistors associated with semiconductor substrates comprising forming a nitrogen-comprising region across an oxide region of a transistor gate	438/216	257/E21.269; 257/E21.625; 438/287; 438/591; 438/770; 438/776	Moore; John T.
US 6649543 B1	20031118	Methods of forming silicon nitride, methods of forming transistor devices, and transistor devices	438/792	257/288; 257/E21.193; 257/E21.268; 257/E21.293; 257/E29.165; 438/216; 438/261; 438/769; 438/775; 438/791	Moore; John T.
US 6645424 B2	20031111	Combustion synthesis of glass (Al ₂ O ₃ -CaO-X-Y) ceramic (TiB ₂) composites	264/649	264/234; 264/80; 501/32; 65/17.4; 65/17.5	Yi; Hu Chun et al.
US 6639243 B2	20031028	DRAM cell constructions	257/68	257/296; 257/347; 257/E21.65	Gonzalez; Fernando et al.
US 6638820 B2	20031028	Method of forming chalcogenide comprising devices, method of precluding diffusion of a metal into adjacent chalcogenide material, and	438/256	257/E29.101; 257/E29.17; 257/E45.002; 438/128; 438/130; 438/942; 438/953	Moore; John T.

		chalcogenide comprising devices			
US 6635530 B2	20031021	Methods of forming gated semiconductor assemblies	438/257	257/E29.165; 257/E29.302; 438/266; 438/268; 438/791	Helm; Mark A. et al.
US 6635043 B2	20031021	Container cap assembly having an enclosed penetrator	604/411	215/247; 215/316; 220/266; 604/415; 604/905	Daubert; Richard F. et al.
US 6631463 B1	20031007	Method and apparatus for patching problematic instructions in a microprocessor using software interrupts	712/227	712/244	Floyd; Michael Stephen et al.
US 6624088 B2	20030923	Method of forming low dielectric silicon oxynitride spacer films highly selective to etchants	438/756	257/E21.268; 257/E21.269; 257/E21.507; 438/789; 438/790; 438/794	Moore; John T.
US 6610041 B2	20030826	Penetrator for a container occluded by a stopper	604/415	141/329; 215/247; 604/411	Daubert; Richard F. et al.
US 6579664 B2	20030617	High performance, photoimageable resin compositions and printing plates prepared therefrom	430/284.1	430/18; 430/283.1; 430/285.1; 430/286.1; 430/287.1; 430/306; 522/100; 522/102; 522/103; 522/110; 522/95	Hu; Yuxin et al.
US D474731 S	20030520	Automobile console	D12/415		Moore; John A.
US 6551973 B1	20030422	Stable metal-safe stripper for removing cured negative-tone novolak and acrylic photoresists and post-etch residue	510/176	510/175; 510/255	Moore; John Cleon

US 6548405 B2	20030415	Batch processing for semiconductor wafers to form aluminum nitride and titanium aluminum nitride	438/688	257/E21.029; 257/E21.035; 257/E21.168; 257/E21.17; 257/E21.292; 257/E21.576; 438/644; 438/660; 438/680	Kraus; Brenda D. et al.
US 6528396 B2	20030304	Transistor and method of making the same	438/484	257/E21.193; 438/761; 438/763; 438/775	Moore; John T.
US 6524295 B2	20030225	Container cap assembly having an enclosed penetrator	604/415	141/329; 215/247; 604/411	Daubert; Richard F. et al.
US 6518626 B1	20030211	Method of forming low dielectric silicon oxynitride spacer films highly selective of etchants	257/344	257/296; 257/336; 257/411; 257/E21.268; 257/E21.269; 257/E21.507	Moore; John T.
US 6515350 B1	20030204	Protective conformal silicon nitride films and spacers	257/640	257/649; 257/760; 257/900; 257/E21.507 CIPG 20060101 A H01L H01L21/02 L I R US M 20060101 CICL H01L CIPS H01L21/02 20060101 CIPG 20060101 A H01L H01L21/3205 L I R US M 20060101 CICL H01L CIPS H01L21/3205 20060101	Moore; John T.

				CIPG 20060101 A H01L H01L21/4763 L I R US M 20060101 CICL H01L CIPS; H01L21/4763 20060101 CIPG 20060101 A H01L H01L21/70 L I R US M 20060101 CICL H01L CIPS H01L21/70 20060101 CIPG 20060101 A H01L H01L21/8238 L I R US M 20060101 CICL H01L CIPS H01L21/8238 20060101 CIPG 20060101 A H01L H01L23/58 L I R US M 20060101 CICL; H01L CIPS H01L23/58 20060101 CIPG 20060101 A H01L H01L23/58 L I R US M 20060101	
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US D469241 S	20030128	Chaps	D2/860	D2/742	Moore; John
US 6498987 B1	20021224	System and method for providing personalized weather reports and the like	702/3		Kelly; Terence F. et al.
US 6481443 B1	20021119	Polish remover pad having protective rim	132/73	15/209.1; 401/8	Moore- Johnson; Misty et al.
US 6463420 B1	20021008	Online tracking of delivery status information over a computer network	705/28	705/26	Guidice; Rebecca R. et al.
US 6463122 B1	20021008	Mammography of computer tomography for imaging and therapy	378/65	378/17; 378/37; 378/64	Moore; John Fitzallen
US 6462402 B2	20021008	Microelectronic substrate comprised of etch stop layer, stiffening layer, and endpointing layer	257/635	257/634; 257/636; 257/637; 257/638; 257/E21.244	Moore; John T.
US 6462371 B1	20021008	Films doped with carbon for use in integrated circuit technology	257/306	257/309; 257/E21.274	Weimer; Ronald A. et al.
US 6461985 B1	20021008	Semiconductor wafer assemblies comprising silicon nitride, methods of forming silicon nitride, and methods of reducing stress on semiconductive wafers	438/791	257/E21.258; 257/E21.293; 257/E21.552; 438/624; 438/758	Moore; John T. et al.
US 6458663 B1	20021001	Masked nitrogen enhanced gate oxide	438/287	257/E21.625; 438/275; 438/591	Moore; John T. et al.
US 6440860 B1	20020827	Semiconductor processing methods of transferring patterns from	438/703	257/E21.206; 257/E21.269; 438/595; 438/724	DeBoer; Scott Jeffrey et al.

		patterned photoresists to materials, and structures comprising silicon nitride		CIPG 20060101 A H01L H01L21/02 L I R US M 20060101 CICL H01L CIPS H01L21/02 20060101 CIPG 20060101 A H01L H01L21/28 L I R US M 20060101 CICL H01L CIPS H01L21/28 20060101	
US 6429151 B1	20020806	Semiconductor wafer assemblies comprising silicon nitride, methods of forming silicon nitride, and methods of reducing stress on semiconductive wafers	438/791	257/610; 257/635; 257/E21.258; 257/E21.293; 257/E21.552; 438/441; 438/57; 438/638	Moore; John T. et al.
US 6429070 B1	20020806	DRAM cell constructions, and methods of forming DRAM cells	438/253	257/E21.65; 438/396	Gonzalez; Fernando et al.
US 6428072 B1	20020806	Vehicle equipment console	296/24.34	224/483; 296/37.12; 296/37.8; 296/70	Moore; John A.
US 6420268 B2	20020716	Methods of forming materials within openings, and methods of forming isolation regions	438/692	257/E21.244; 257/E21.55; 438/700; 438/723; 438/724	Moore; John T. et al.
US 6417559 B1	20020709	Semiconductor wafer assemblies comprising photoresist over	257/640	257/629; 257/632; 257/639; 257/E21.257;	Moore; John T. et al.

		silicon nitride materials		257/E21.259; 257/E21.293	
US 6391738 B1	20020521	Semiconductor processing method and trench isolation method	438/402	257/E21.318; 257/E21.546; 438/143; 438/471; 438/477	Moore; John T.
US 6391710 B1	20020521	Methods of forming capacitors	438/253	438/634; 438/740; 438/970	Moore; John T. et al.
US 6385351 B1	20020507	User interface highlighter function to provide directed input for image processing	382/312	382/282; 382/311; 382/319	Simske; Steven J. et al.
US 6365519 B2	20020402	Batch processing for semiconductor wafers to form aluminum nitride and titanium aluminum nitride	438/688	257/E21.029; 257/E21.035; 257/E21.168; 257/E21.17; 257/E21.292; 257/E21.576; 427/255.391; 438/660; 438/680	Kraus; Brenda D. et al.
US 6362105 B1	20020326	Method and apparatus for endpointing planarization of a microelectronic substrate	438/692	216/38; 216/85; 216/88; 216/91; 257/E21.244; 438/745; 438/8	Moore; John T.
US 6348380 B1	20020219	Use of dilute steam ambient for improvement of flash devices	438/257	257/E21.209; 257/E29.165; 438/593; 438/594; 438/773	Weimer; Ronald A. et al.
US 6348365 B1	20020219	PCRAM cell manufacturing	438/130	257/E45.002; 438/466; 438/95	Moore; John T. et al.
US D453318 S	20020205	Automobile console	D12/415		Moore; John A.
US 6342437 B1	20020129	Transistor and method of making the same	438/474	257/E21.193; 438/761; 438/763	Moore; John T.
US 6339747 B1	20020115	Weather tracking and display system and	702/3		Daly; Richard T.

		method			et al.
US 6335765 B1	20020101	Virtual presentation system and method	348/586	345/419; 345/629; 348/587; 348/598	Daly; Richard T. et al.
US 6328345 B1	20011211	Secondary tubing containment system for a metering pump	285/123.1	285/123.15; 285/13; 285/302; 285/343	Moore; John C. et al.
US 6326321 B1	20011204	Methods of forming a layer of silicon nitride in semiconductor fabrication processes	438/791	257/E21.029; 257/E21.206; 257/E21.257; 257/E21.293; 438/520; 438/775	DeBoer; Scott Jeffrey et al.
US 6323139 B1	20011127	Semiconductor processing methods of forming photoresist over silicon nitride materials	438/786	257/E21.257; 257/E21.259; 438/757; 438/769; 438/775; 438/787; 438/791	Moore; John T. et al.
US D450323 S	20011113	Printer properties graphical user interface computer icon for a display	D14/485		Moore; John Anthony et al.
US 6316372 B1	20011113	Methods of forming a layer of silicon nitride in a semiconductor fabrication process	438/791	257/E21.029; 257/E21.206; 257/E21.257; 257/E21.293; 438/520; 438/775	DeBoer; Scott Jeffrey et al.
US 6314433 B1	20011106	Frame-based heroic data recovery	707/202	360/53; 714/758	Mills; Mark E. et al.
US 6300671 B1	20011009	Semiconductor wafer assemblies comprising photoresist over silicon nitride materials	257/639	257/629; 257/632; 257/640; 257/E21.257; 257/E21.259	Moore; John T. et al.
US 6300253 B1	20011009	Semiconductor processing methods of forming photoresist over silicon nitride materials, and	438/763	257/E21.257; 257/E21.259; 438/757; 438/769; 438/778; 438/786;	Moore; John T. et al.

		semiconductor wafer assemblies comprising photoresist over silicon nitride materials		438/791	
US 6277081 B1	20010821	Anesthetic gas detection apparatus	600/532	250/345	Susi; Roger et al.
US 6274498 B1	20010814	Methods of forming materials within openings, and method of forming isolation regions	438/692	257/E21.244; 257/E21.55; 438/700; 438/723; 438/724	Moore; John T. et al.
US 6271153 B1	20010807	Semiconductor processing method and trench isolation method	438/787	257/E21.318; 257/E21.546; 438/437; 438/763; 438/783; 438/795	Moore; John T.
US 6263122 B1	20010717	System and method for manipulating regions in a scanned image	382/311		Simske; Steven J. et al.
US 6251802 B1	20010626	Methods of forming carbon-containing layers	438/778	257/E21.008; 257/E21.27; 438/623; 438/766; 438/780; 438/783; 438/924	Moore; John T. et al.
US 6234262 B1	20010522	Snowmobile steering and suspension system	180/182	180/186; 180/190; 280/93.51	Moore; John W.
US 6230632 B1	20010515	Selectively variable modular space system with shelving and enclosures	108/180	211/194; 312/108; 312/265.4	Moore; John C.
US 6218293 B1	20010417	Batch processing for semiconductor wafers to form aluminum nitride and titanium aluminum nitride	438/644	257/E21.029; 257/E21.035; 257/E21.168; 257/E21.17; 257/E21.292; 257/E21.576	Kraus; Brenda D. et al.
US D440077 S	20010410	Combined newspaper holder and storage device	D6/466		Castillo; Earl J et al.

US 6214697 B1	20010410	Trench isolation for semiconductor devices	438/424	257/E21.546; 438/296; 438/435; 438/437; 438/761	Moore; John T. et al.
US 6200691 B1	20010313	Oxidation resistance coating system for refractory metals	428/615	428/627; 428/641; 428/655; 428/663; 428/664	Moore; John J. et al.
US 6194321 B1	20010227	Semiconductor processing methods utilizing boron and nitrogen, and semiconductor wafers comprising boron and nitrogen	438/706	257/E21.029; 257/E21.292; 438/708; 438/710; 438/711; 438/716; 438/717	Moore; John T. et al.
US 6188538 B1	20010213	Retry off-track positioning table	360/77.04	369/53.37; 714/15; 714/710	Mills; Mark E. et al.
US 6184571 B1	20010206	Method and apparatus for endpointing planarization of a microelectronic substrate	257/635	257/915; 257/E21.244; 438/634	Moore; John T.
US 6162737 A	20001219	Films doped with carbon for use in integrated circuit technology	438/738	257/437; 257/E21.274; 438/216; 438/784; 438/970	Weimer; Ronald A. et al.